

Notice of References Cited	Application/Control No. 10/553,029		Applicant(s)/Patent Under Reexamination DELPUECH ET AL.	
	Examiner Thomas K. Pham		Art Unit 2121	Page 1 of 1

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*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
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*	B	US-5,809,787	09-1998	Zittel, David R.	62/63
*	C	US-4,966,003	10-1990	Shima, Yoshisuke	62/63
*	D	US-6,895,775	05-2005	Newman et al.	62/378
*	E	US-6,796,142	09-2004	Burn, Mark	62/380
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*	I	US-6,214,400	04-2001	Zittel et al.	426/509
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*	K	US-5,813,237	09-1998	Grace et al.	62/52.1
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NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Author: H. Koivisto, J. DeKamp, A. Zeller Title: Cooling of the plasma chamber for the AECR-U type electron cyclotron resonance ion source ARTEMIS Date: June 22, 2000
	V	Author: Roger Toogood Title: Pro/MECHANICA Tutorial Structure Date: 2001 Publisher: SDC
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.